

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L2	15	"polysilicon resistor" and resistance and implant\$4 and anneal\$3 and gate and source and drain and (dielectric or insulating).clm.	US-PGPUB	OR	ON	2006/05/26 09:21
L3	69	coolbaugh-douglas-d.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/26 09:23
L4	6	greer-heidi-l.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/26 09:24
L5	8	rassel-robert-m.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/26 09:24